

Laser lines for run 2c

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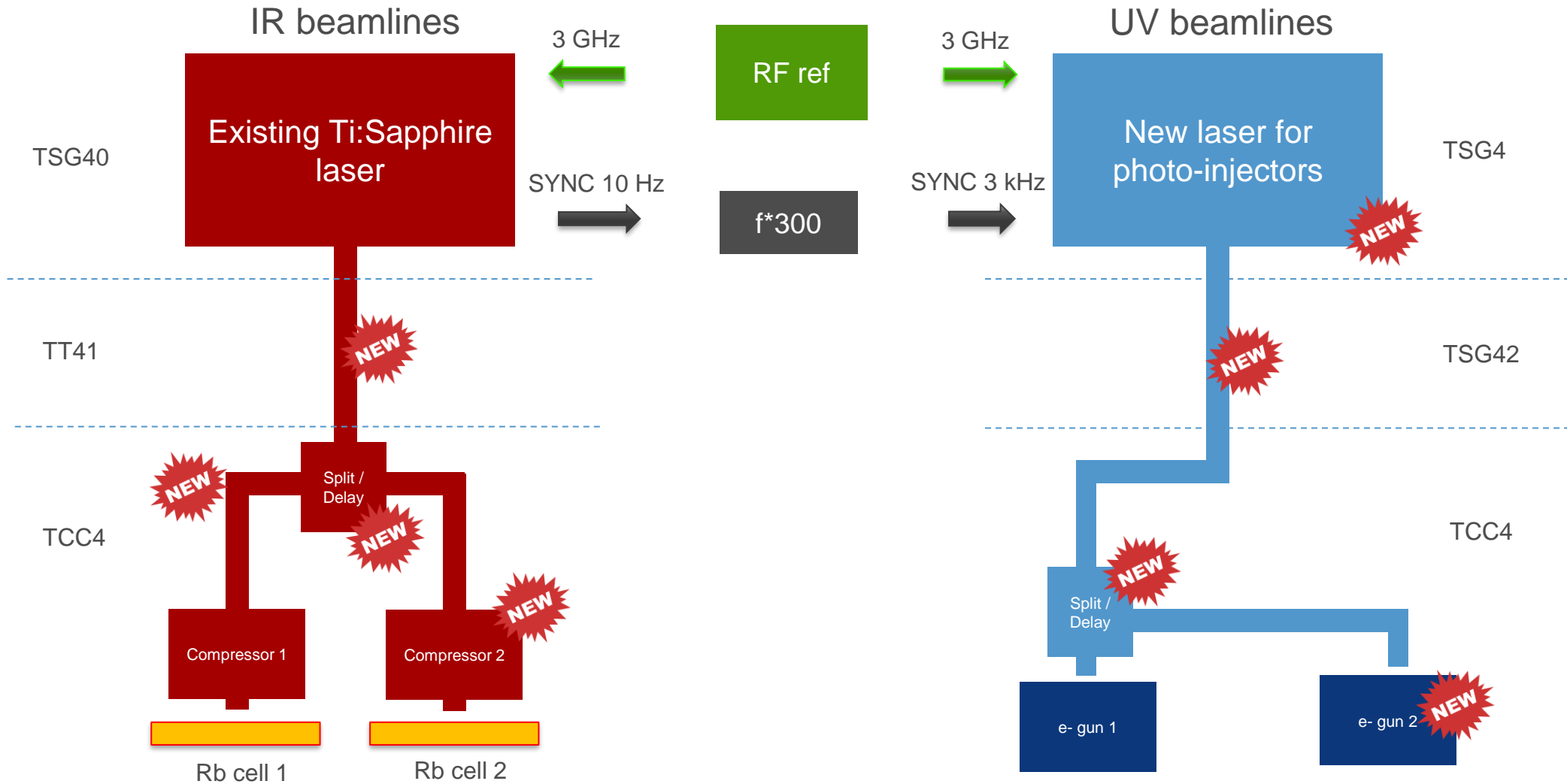
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Agenda

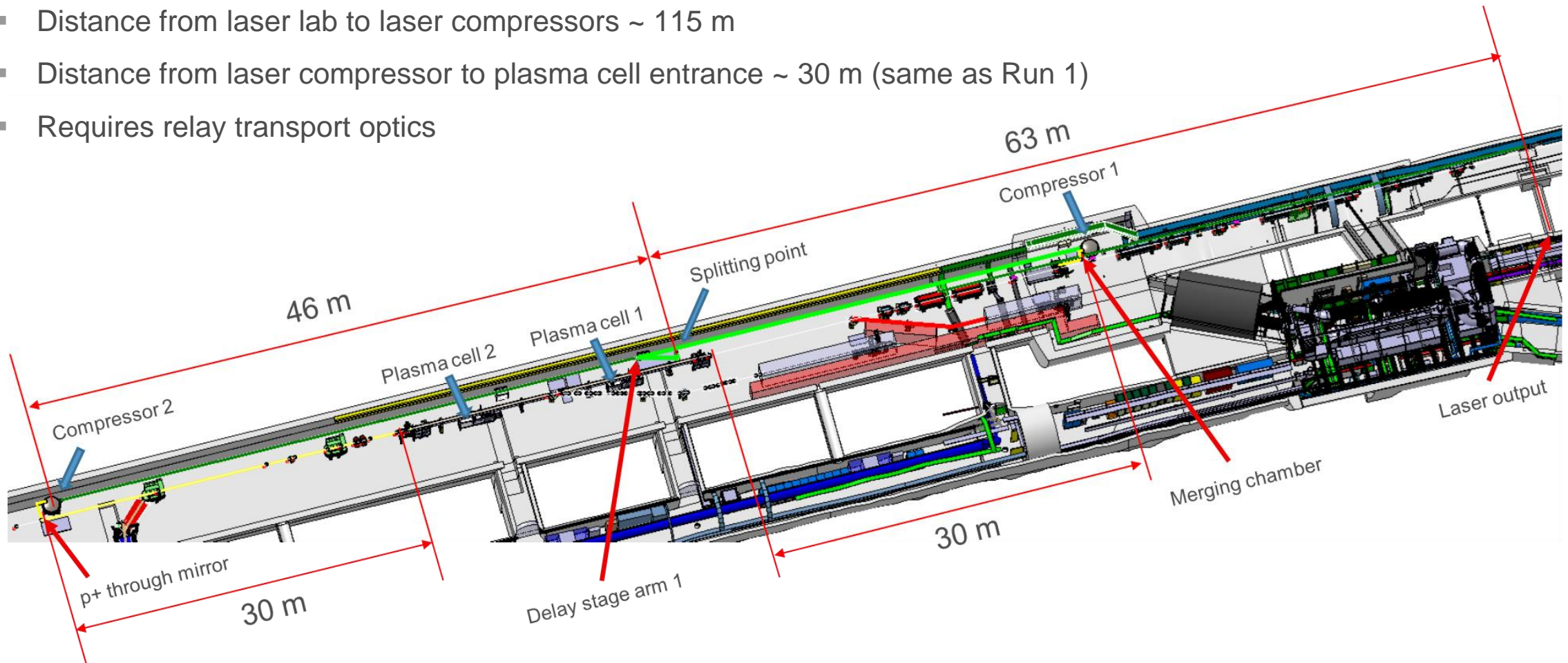
- Overview of laser lines for run 2c
 - IR beamlines
 - UV beamlines
 - Electron beams generation
- Status of new photoinjector
 - Laser performance
 - Photocathode performance
- Outlook and conclusions

Laser beams concept for Run 2c



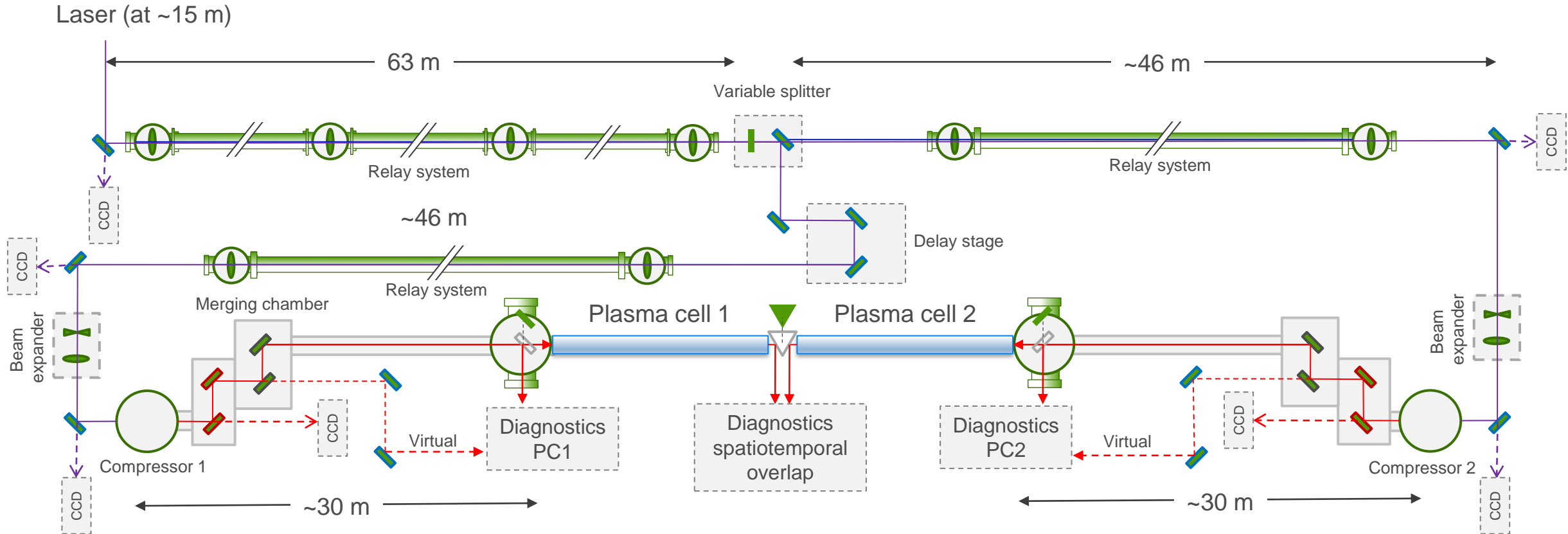
IR beamlines for run 2c

- Distance from laser lab to laser compressors ~ 115 m
- Distance from laser compressor to plasma cell entrance ~ 30 m (same as Run 1)
- Requires relay transport optics



Floorplan courtesy of P. Wiwattananon

IR beamlines for run 2c



- Stretched pulse
- Compressed pulse
- Mirror leak

- Relay imaging systems require only low-level primary vacuum, blue mirrors are “in air”
- Focusing on plasma cell attained by mismatching beam expanders
- Content of diagnostics sets still to be determined, location of safety devices, etc...

IR beamlines for run 2c

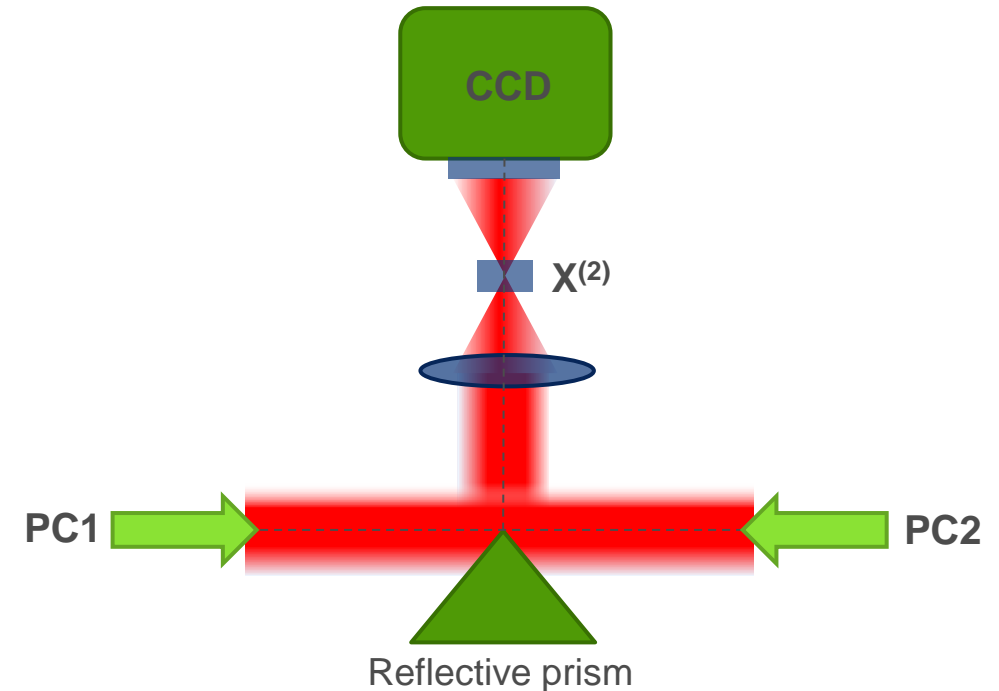
Diagnostics pre-PC1 and pre-PC2 “Beam conditioning section”

Parameter	Diagnostic	Control
Pulse energy	Energy meter (leak / real beam)	TBD
Beam position	Virtual camera (BI?)	Motorized mirrors (stepper or picomotor)
Timing (arm 1)	Spatiotemporal overlap diagnostics table	Delay stage
Beam size	Virtual and real imaging (BI?)	Beam expander
Pulse duration	Auto-correlator	Motorized compressor

Diagnostics spatiotemporal overlap (mostly TBD) “Beam matching section”

Parameter	Diagnostic	Control
Relative beam positions	CCD camera (BI?)	Motorized mirror (stepper motor)
Timing	X-correlator / fast PD	Delay stage
Beam sizes	CCD camera (BI?)	Beam expander

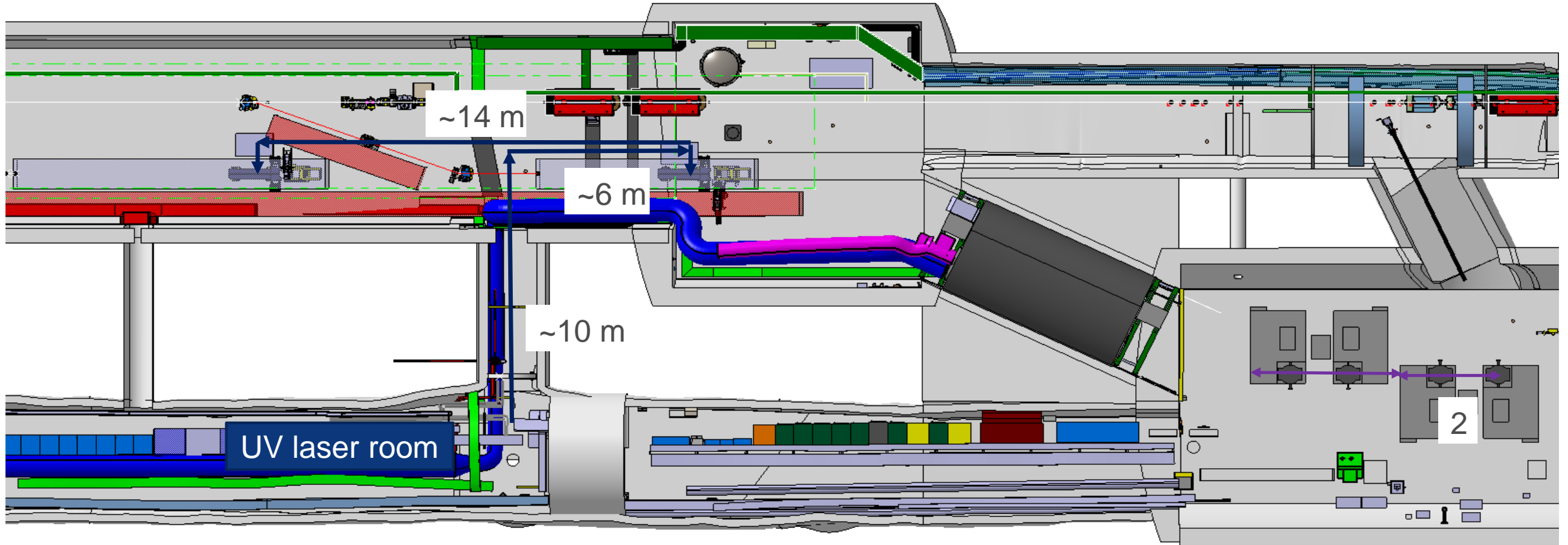
To be developed



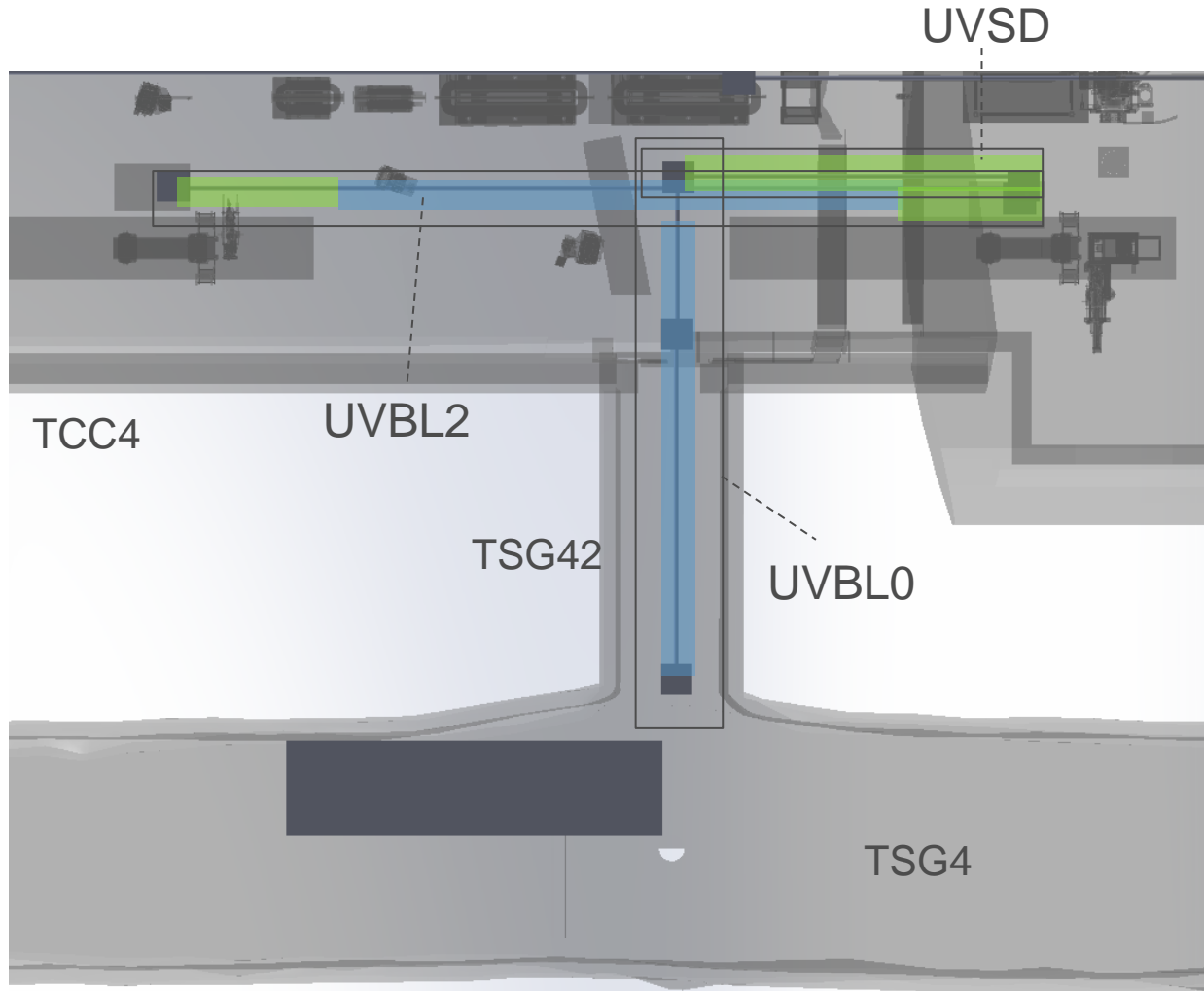
Unfortunately this device is located at the injection point of e- bunch to 2nd cell

UV beamlines for run 2c




A dedicated UV laser in TSG4



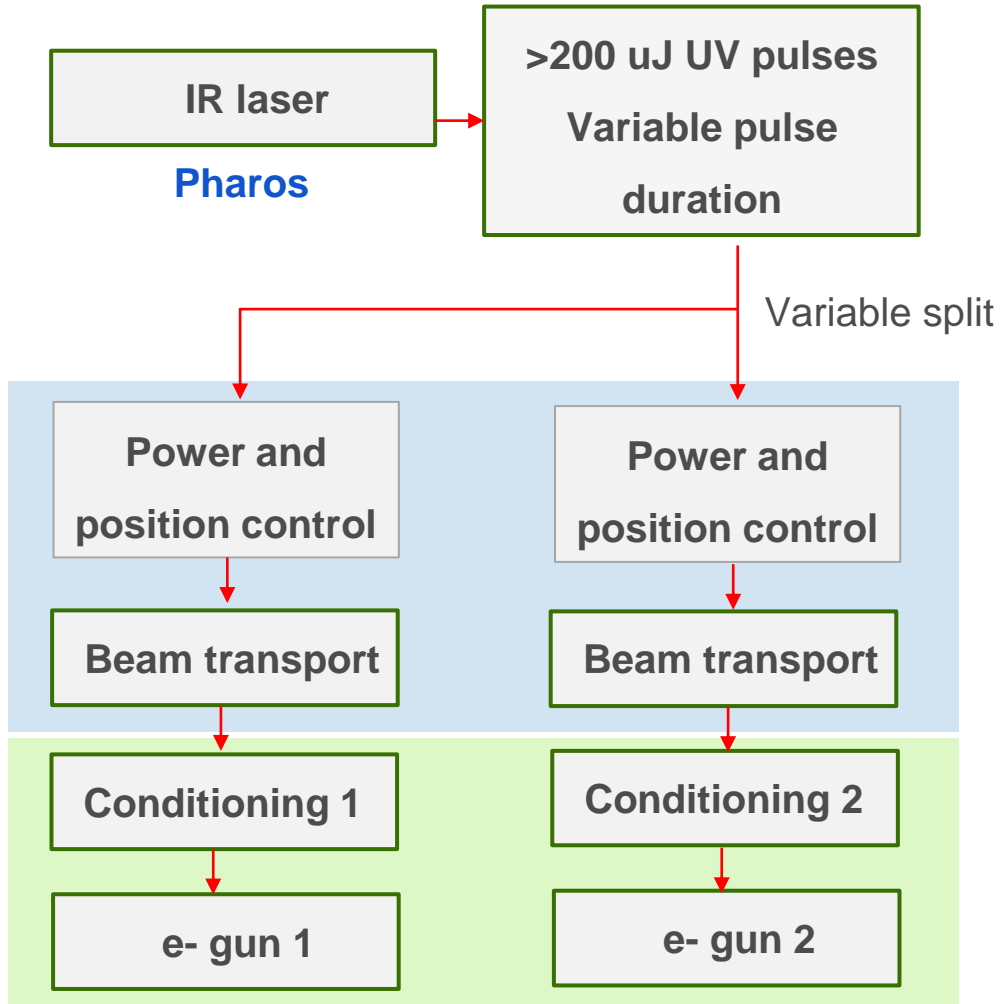
UV beamlines for run 2c



- UVBL0: UV Beamline from UV laser lab to 1st electron gun (UV Split and delay sub-system)
- UVSD: UV Split and delay system, produces UV beams for each e-gun
- UVBL2: UV Beamline from gun 1 to gun 2

-  No vacuum
-  Primary vacuum
-  UHV

UV beamlines for run 2c



***Baseline (for Cs₂Te photocathodes)**

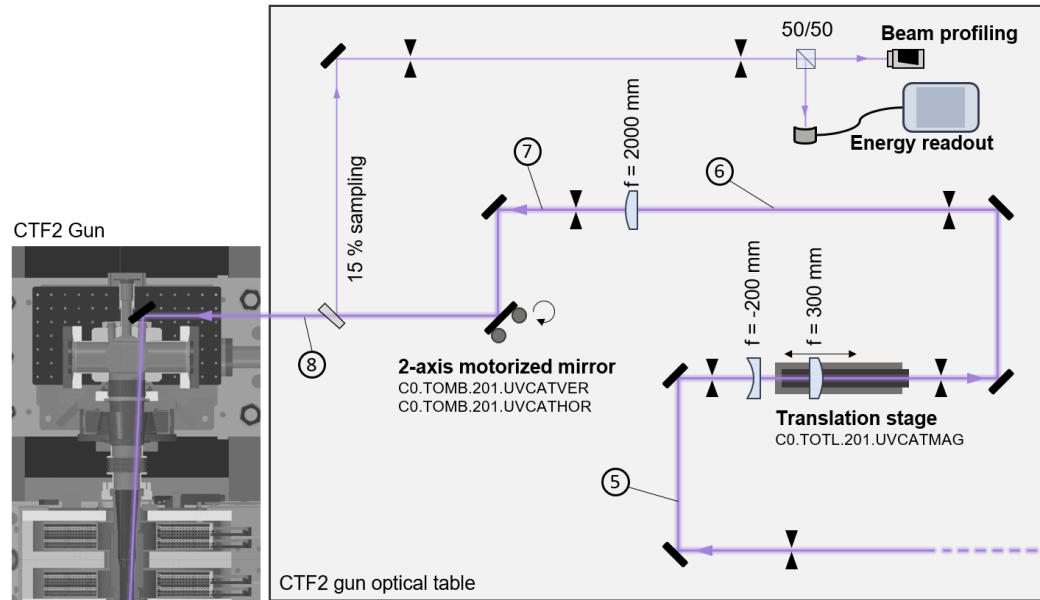
UV Beam transport diagnostics and controls for each line

Parameter	Diagnostic	Control
Pulse energy (IR+UV)	Samplers + energy meters	Motorized waveplates
Beam positioning	Leakage cameras	Motorized mirrors (picomotor)

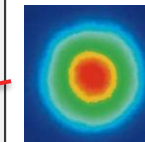
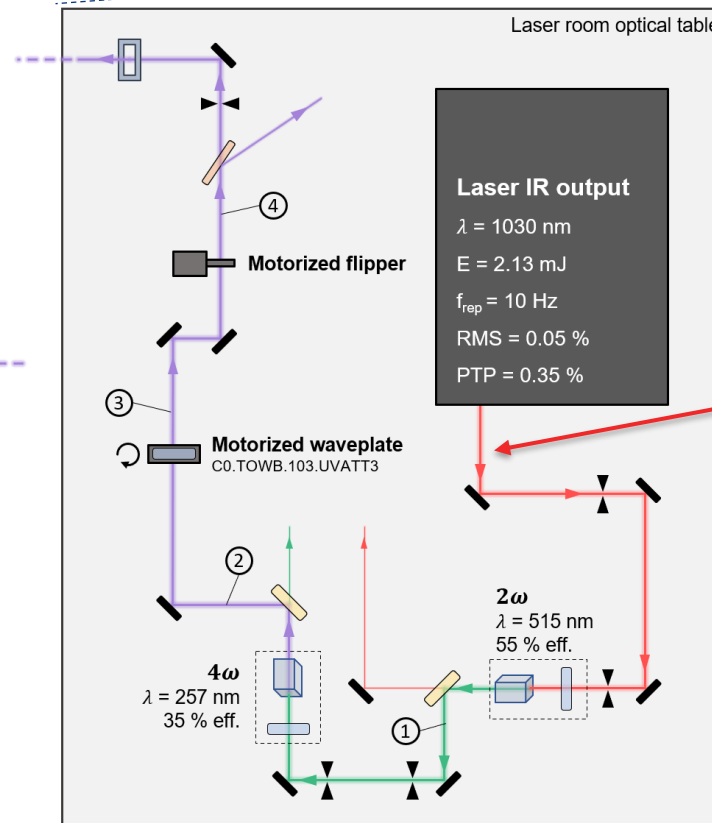
UV Beam conditioning diagnostics and controls for each line

Parameter	Diagnostic	Control
Pulse energy	Sampler + energy meter	Motorized filterwheel
Beam position	Virtual cathode camera	Motorized mirror (stepper motor)
Timing	Sampler + photodiode	Delay stage
Beam size	Virtual cathode camera	Motorized iris
UV pulse duration	X-correlator / streak camera	Motorized compressor or UV stretcher

UV beamlines for run 2c: New photoinjector laser



Optical setup of CTF2 Photoinjector laser and energy stability



Conversion efficiency:

- IR to green ~60%
- Green to UV ~30%
- Overall ~ **18%**

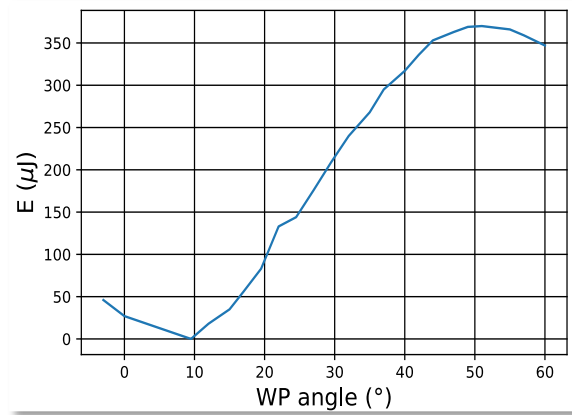
Photocathode

- Dichroic mirror
- $\lambda/2$ waveplate
- Thin Film Polarizer
- Beam splitter
- Interlocked shutter
- β - BBO crystal
- Iris
- Mirror
- Plano-concave/convex lens

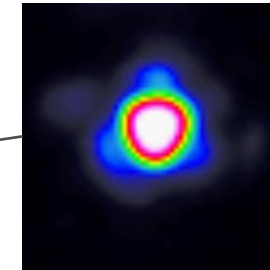
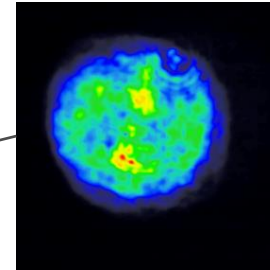
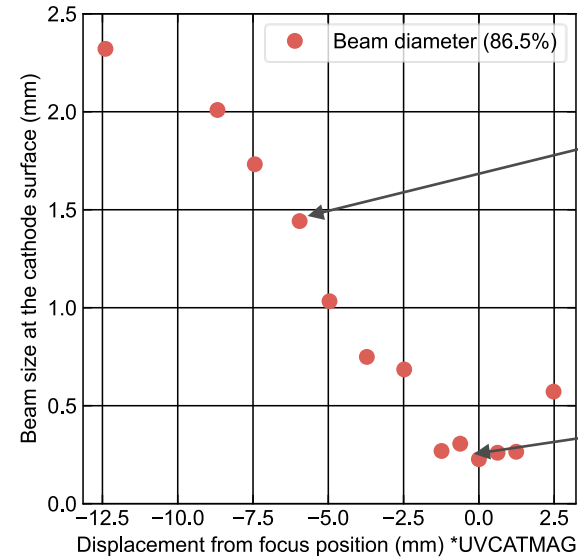
		E (μ J)	RMS (%)	PTP (%)
515 nm	1	1240	0.06	0.48
	2	480	0.09	0.56
	3	435	0.07	0.53
	4	427	0.07	0.45
257 nm	5	369	0.16	0.95
	6	304	0.45	5.39
	7	286	0.61	5.89
	8	245	1.04	11.70

UV beamlines for run 2c: New photoinjector laser

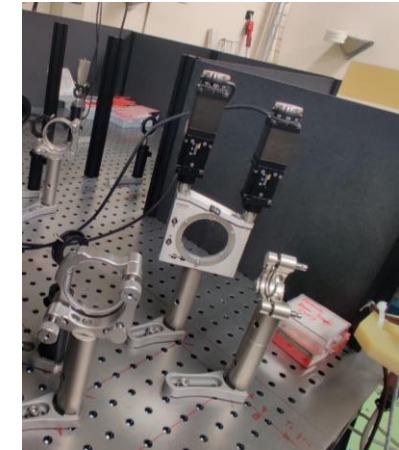
UV pulse energy control



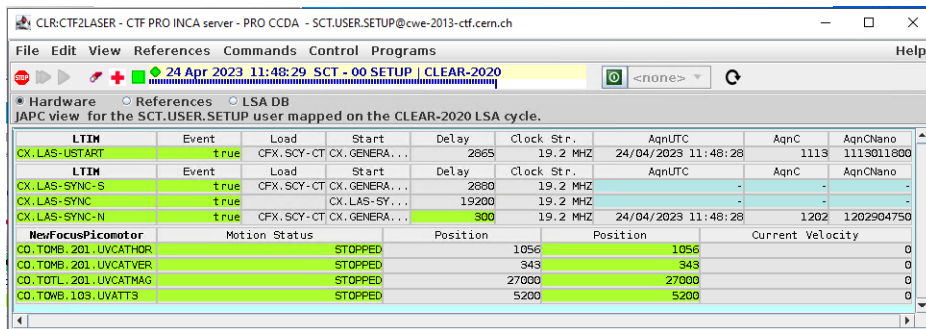
UV spot size control



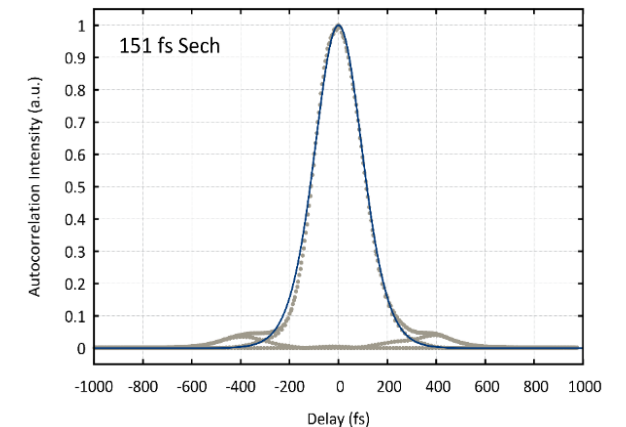
UV position on cathode



Controls integrated in WorkingSet



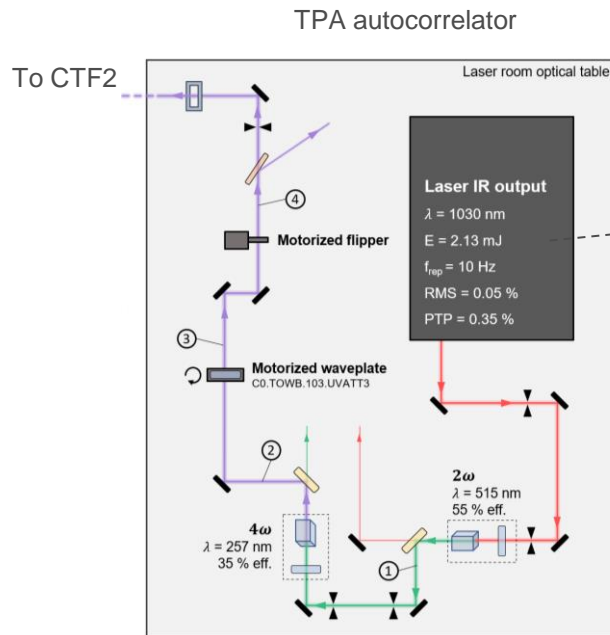
Last tests and improvements:
UV pulse duration



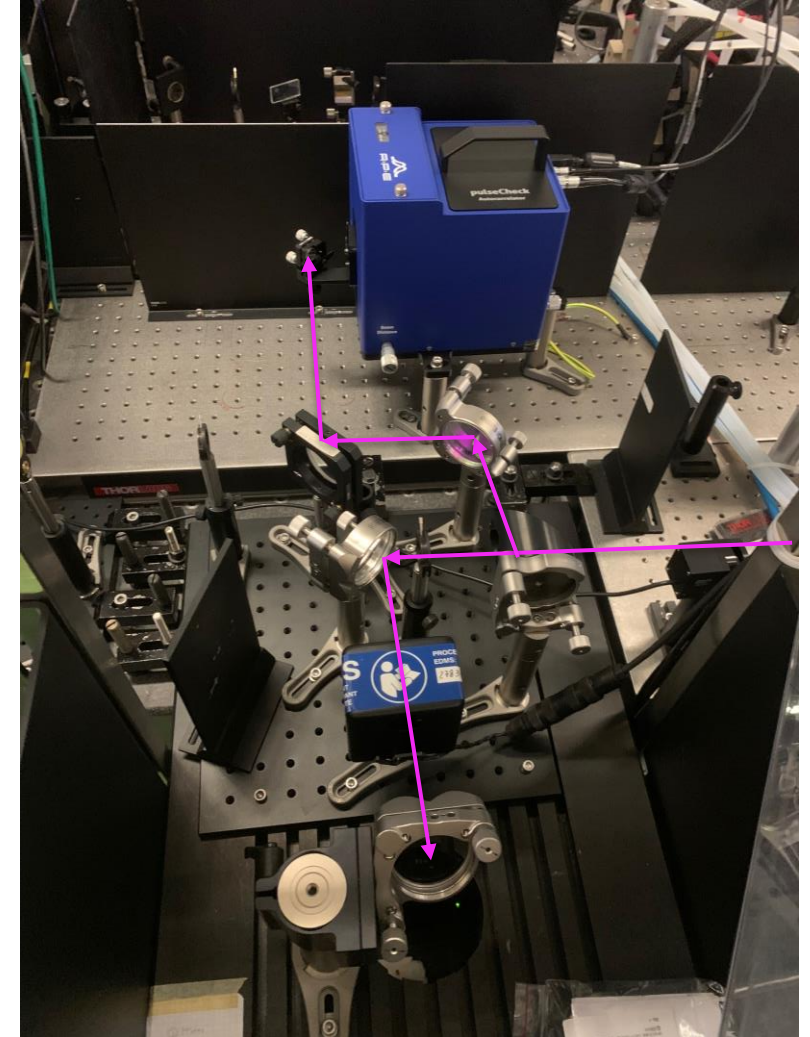
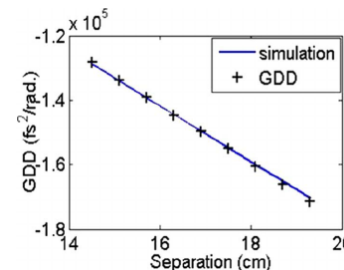
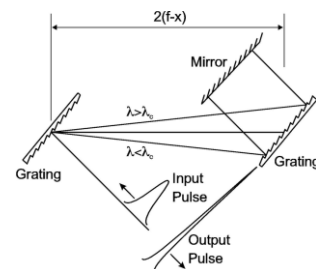
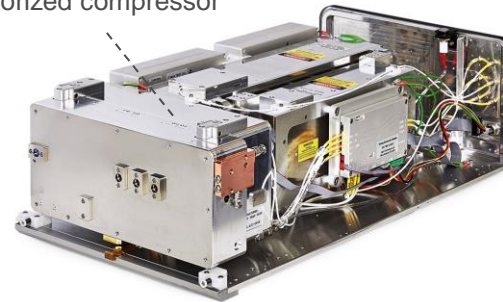
UV beamlines for run 2c: New photoinjector laser

Setup for control and measurement of UV pulse duration

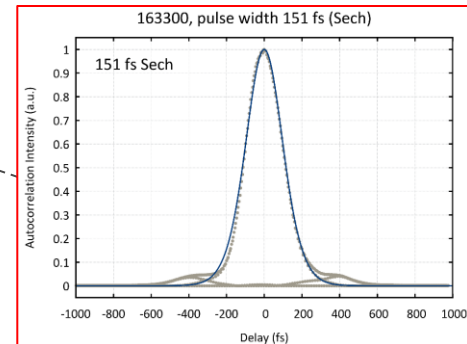
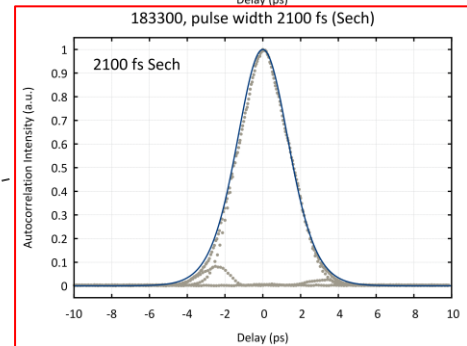
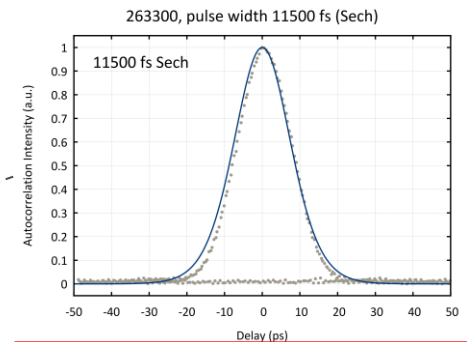
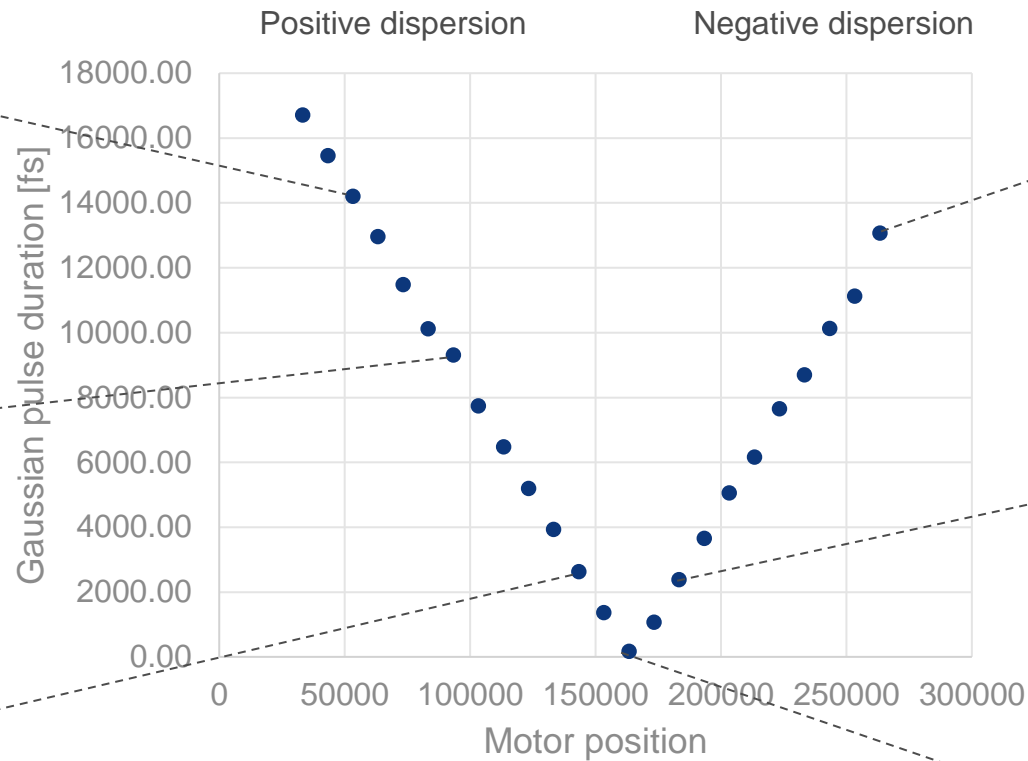
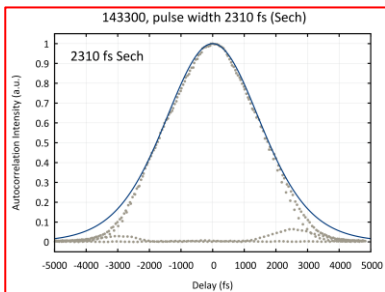
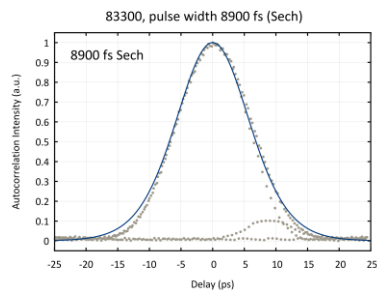
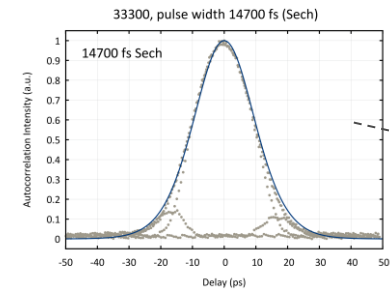
- “online” measurement of UV pulse duration, remotely operated
- Remote control for grating separation in laser compressor allows selectable IR pulse duration during operation.
- IR and DUV pulse duration are non-linear related, so the duration is not directly predictable with accuracy.
- Existence of dispersion in the UV line and B-integral



Motorized compressor

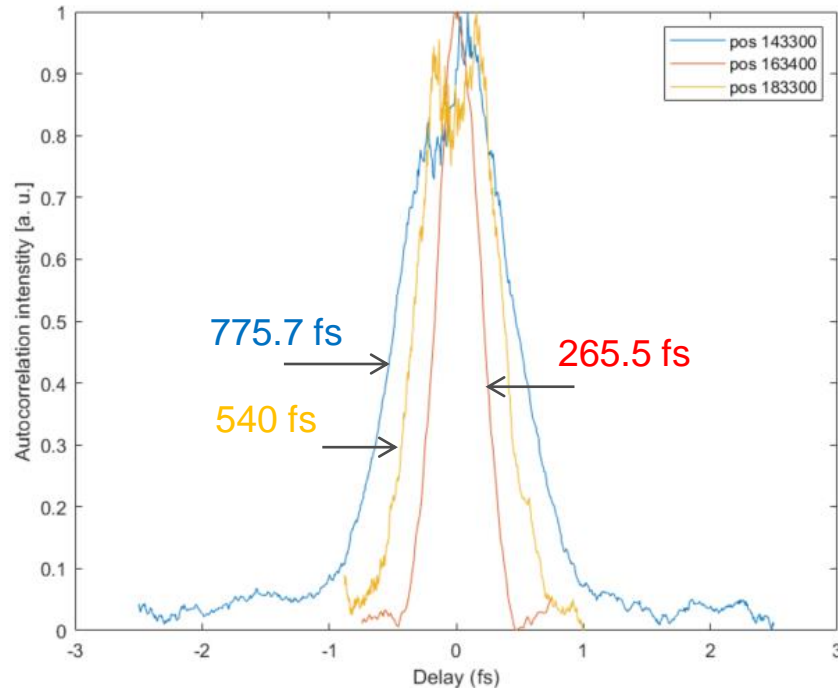


UV beamlines for run 2c: New photoinjector laser



- To solve B-integral and study space charge effect in CTF2 photoinjector, 3 pulse durations in the IR were tested.

UV beamlines for run 2c: New photoinjector laser



Motor position	IR pulse duration*	UV pulse duration*
163400	151 fs	265.5 fs
143300	2100 fs (negative chirp)	540 fs
183300	2310 fs (positive chirp)	775.7 fs

* Deconvolved values are given at FWHM for Gaussian fits

- The UV pulse energy was reduced to 65 uJ (by a factor of 6.2) when the longer IR pulse was used.
- For the 775 fs pulse, the energy delivered on the cathode was around 35 uJ. The energy stability was better, going to below 1% RMS on cathode

UV beamlines for run 2c: New photoinjector laser

Operational
Emission on!

2.001 W
2.001 W / 1 · 100%

1.0 kHz
1.0 / 1

1998.5 μ J

1030 nm

Output control

Output enabled

Attenuator: 100.0%

Divider: 1

Presets

Preset	Power	Frequency	Energy
11	2.0 W	1.0 kHz	2 mJ 1 kHz
Last used parameters			
1	-1.0 W	-1.0 kHz	Invalid dummy preset
2	2.0 W	1.0 kHz	2 mJ - 1 kHz - 1ps sigma
3	2.0 W	1.0 kHz	2 mJ - 1 kHz + 1 ps sigma
4	6.0 W	200.0 kHz	1030 nm, 30 μ J
5	6.0 W	30.0 kHz	1030 nm, 200 μ J
6	6.0 W	10.0 kHz	1030 nm, 600 μ J
7	6.0 W	6.0 kHz	1030 nm, 1 mJ

PhaseLock MCGP

7. Offs. X adjustment 1: Gain X 1500 MHz, Ref freq, Offs. Y 12%, Gain Y 12%, in clip, Phase 0.120, Dark adjust, 1 bit, error scale

Input adjustment 2: Gain X 75 MHz, Ref freq, Offs. X 0.068, Offs. Y 124%, Gain Y 124%, in clip, Phase 0.045, Dark adjust, 0 bits, error scale

F adjustment: max. radius 9.500 V, min. radius 1.000 V, Max. freq. 100.0 kHz, Radius 1.8 V, Frequency 0.0 kHz, Phase 5°, Amplitude / radius in range, Frequency in range, Searching, 10.677 ns, Reg On/Off

Piezo regulator A: Set Point 0.000 V, gain reduction 10.000%, "locked" Threshold -20, 0.022%, enable, Sign negative, reset 0.000 V, Off Mode, locked, hold, Filter Mode, 30.000%, out. range, search speed, Out. Offset

Piezo regulator B: error thrshld 1%, gain reduction 5.000%, "locked" Threshold -20, -5.906%, enable, Sign positive, reset 0.000 V, Off Mode, locked, hold, Filter Mode, 50.000%, out. range, search speed, Out. Offset

Regulator A output: out clip, request, 0.033 V, 0.046 V, reg. out, output

Regulator B output: out clip, request, 1.631 V, 0.940 V, reg. out, output

Step Response: Step Width 8.146°, Step Rate SF#65536, Step Duration 52.428 ms, couple step

Communication: COM Parameters, COM Window, Debug Window, save to μ C, load from μ C, save to disk, load from disk, open COM port, 1389319 serial number, 201218000 FPGA firmware, 1428 Build number

Scan Generator: Scan On/Off, busy with go to, 0.02 speed limit, 1.000 ns width, ramp shape, bipolar unipolar, off sinusoidal, continuous continuous/step, 0.100 step size, 0.010 ms step duration, 10 nmb of steps

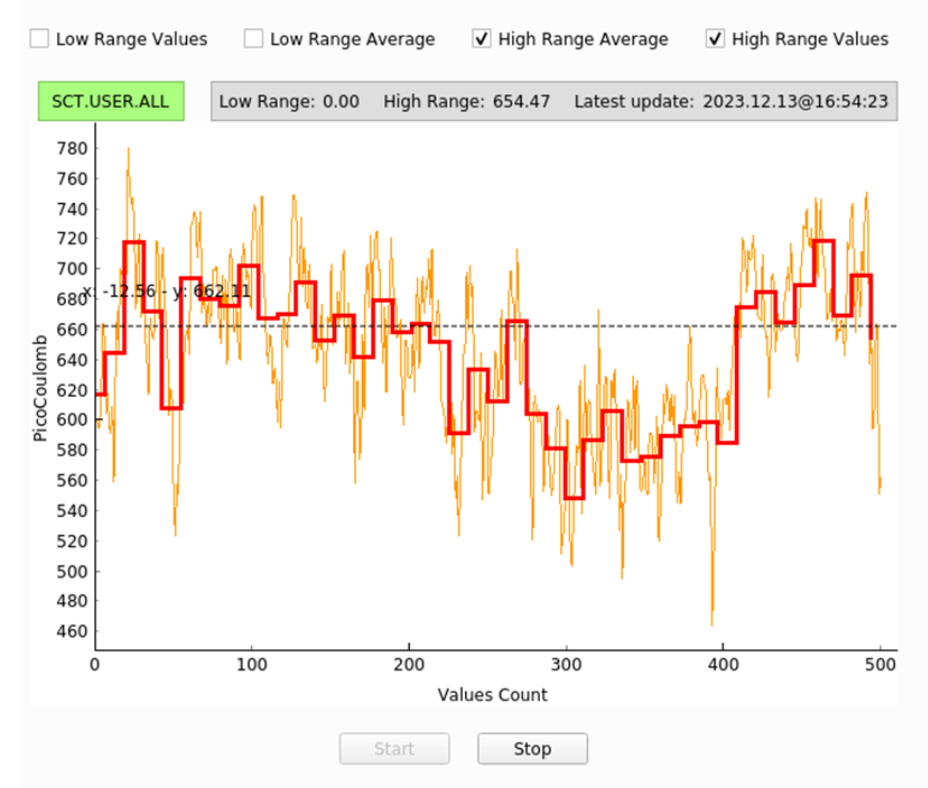
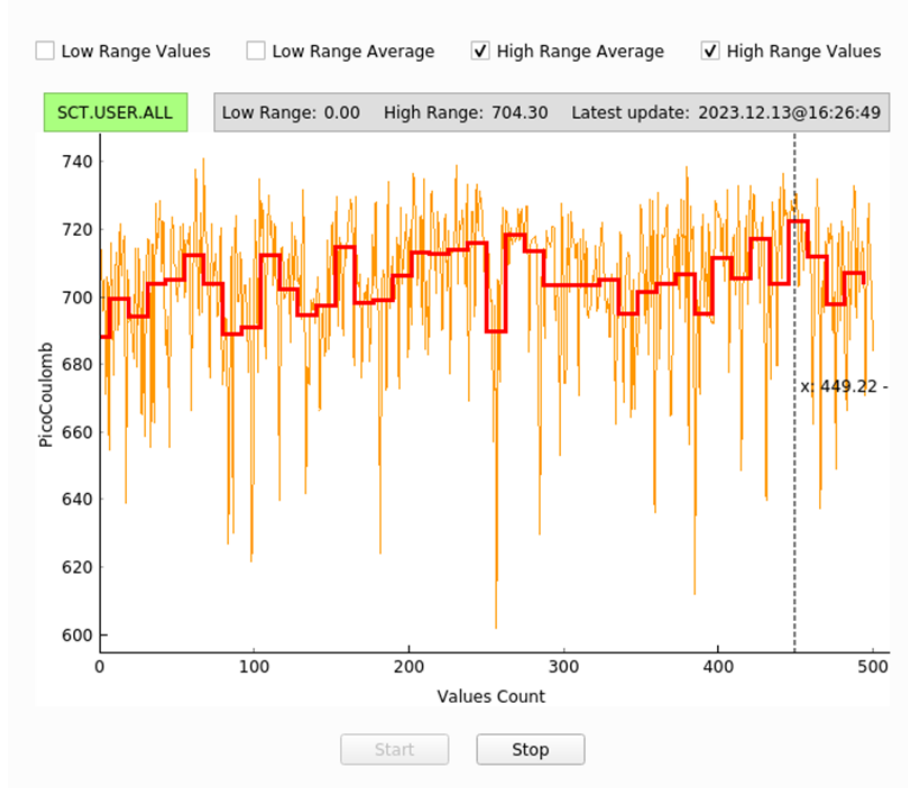
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UV beamlines for run 2c: New photoinjector laser

- Maximum bunch charge tests!
- Checked at both pulse lengths (better stability with longer pulse, from 1% to 5%)

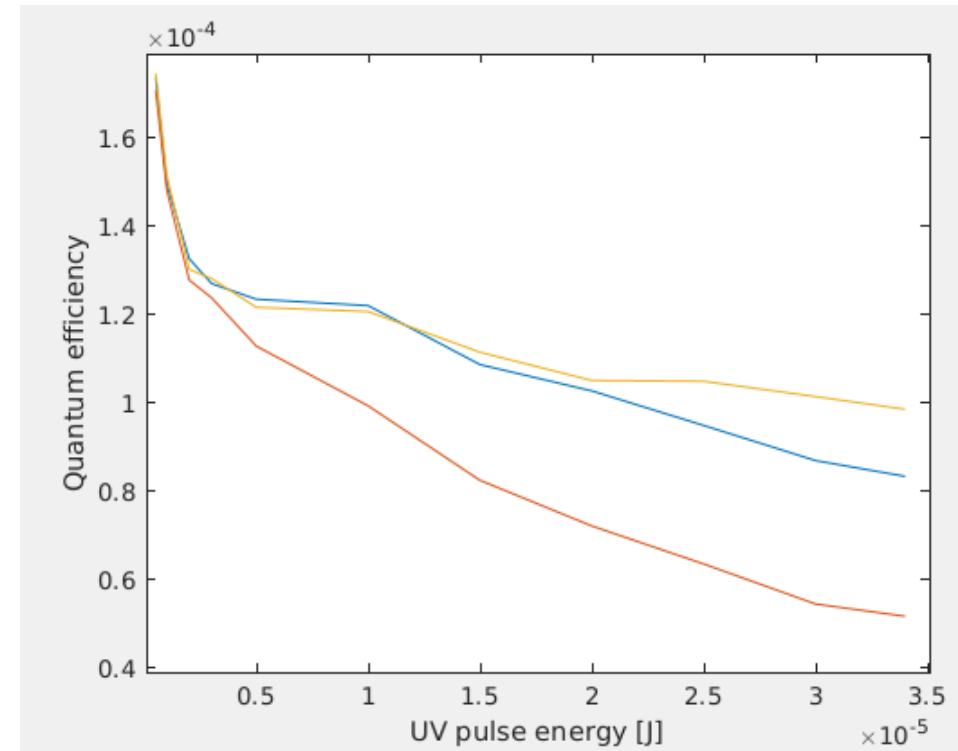
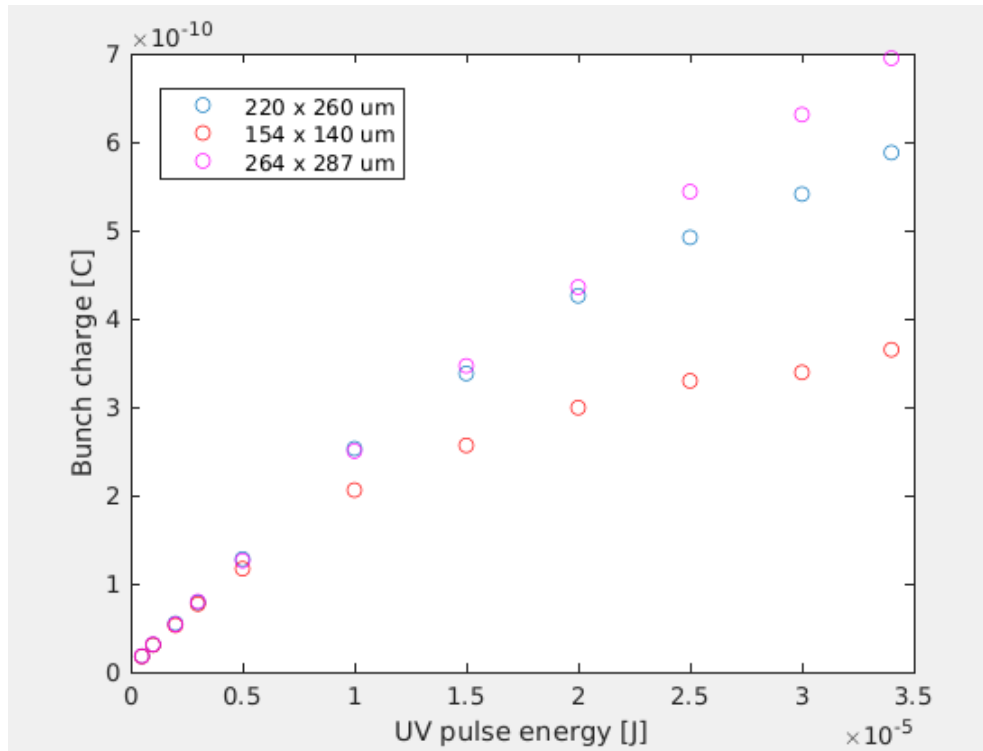
700 pC bunch charge!!! 775.7 fs (FWHM) UV pulse length

Again 700 pC bunch charge 265.5 fs (FWHM) UV pulse length



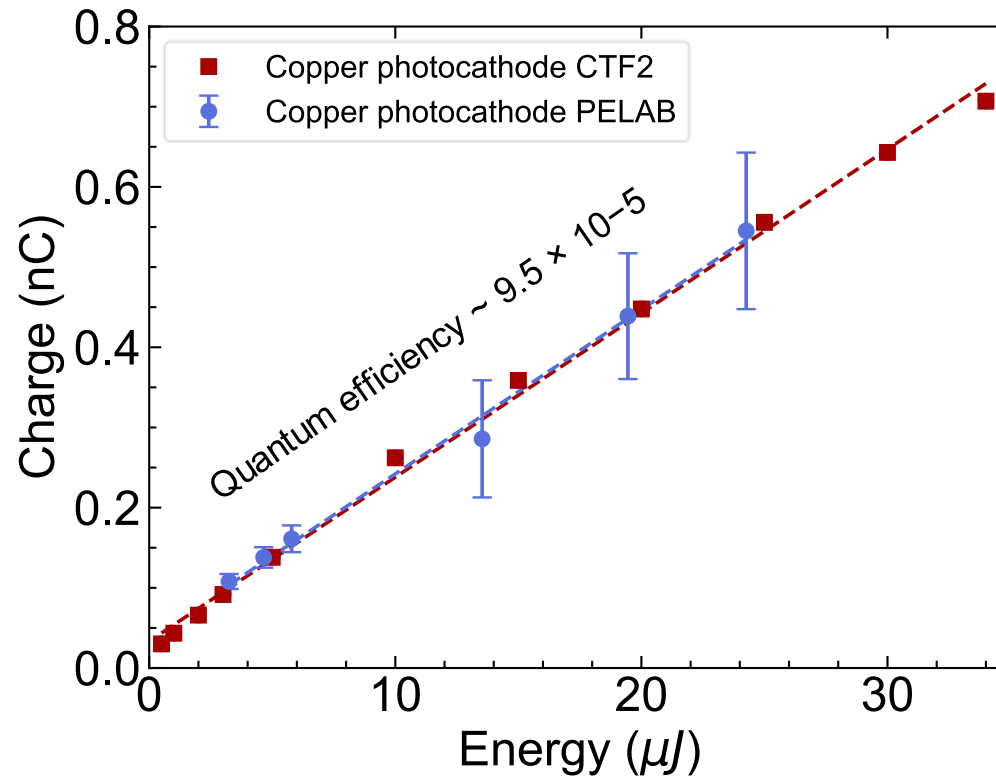
UV beamlines for run 2c: New photoinjector laser

- Systematic measurements of the QE with the new pulse length at 3 different magnifications (beam size at the photocathode surface)
- Very nice saturation curves!



UV beamlines for run 2c: New photoinjector laser

QE measurements with different fields (PELAB = **6.5 MV/m** Vs CTF-2 = **100 MV/m**)



Laser beamlines: open questions, outlook

- **IR beams**

- Timing resolution required for synchronization -> Development of specific optical/electronic diagnostics
- 2nd Compressor vessel design -> size, location
- Pulse energy required in each cell? -> May not need reflective telescopes?

- **UV beams**

- Preferable option is to use a separate laser (as in CLEAR) due to:
 - Synchronization with ionizing laser without additional delay lines (~ 80 m extra)
 - Location of compressors and harmonic stages (laser lab, near gun?) -> better pointing stability
 - Higher energy of UV pulse
 - Possibility to produce electron beams independently of the main laser status
- Pulse duration tunability capabilities, ranges? Variable compressor/stretcher? Different pulse durations for each e- gun? CLEAR/CTF2 tests will help answering these questions

New photoinjector conclusions

- The photoinjector laser for AWAKE run 2c is ready and operative, alongside with controls and diagnostics.
- The integration of cesium telluride cathodes at CTF2 is under study, with a view on simplifying the future AWAKE run2c layout and cost.
- The pulse duration capability has been tested and optimized allowing flexibility in the experiment.
- Photocathode material for fs gun -> emittance and charge requirements -> UV energy needs.

Thank you for
your attention!

